



Analysis, Design and Industrial Application of Intelligent Control Systems

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Deadline for manuscript
submissions:

closed (10 December 2023)

Message from the Guest Editors

This Special Issue invites contributions that address these challenges and showcases the latest real-world applications and enabling advancements in the analysis and design of Intelligent Control systems (ICS) in industrial settings, e.g., systems, biomedical systems and assisted living technologies. We invite novel research contributions that are based on (but not limited to) the following topics:

- Analysis and design of ICS;
- Security;
- Privacy;
- ICS technologies;
- Applications of cyber physical systems;
- ICS laws and regulations;
- ICS sectors;
- Industry 4.0;
- IoT ecosystems.





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Message from the Editor-in-Chief

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